



[0]: Response

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Title: USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE Group Art Unit: 2813

Examiner:

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Lisa Kilday

Atty. Docket:

94-028004

ECEINEU JULI AOOT

RESPONSE TO THE OFFICE ACTION DATED AUGUST 6, 2001

Assistant Commissioner for Patents Washington, D.C. 20231

Dear Sir:

Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to:

Assistant Commissioner for Patents

Washington, DC 20231 on

Date ///8/01

Signature

Applicants herein respond to the Office Action dated August 6, 2001.

REMARKS

Claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43 are pending.

Claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43 are rejected.

Applicants request reconsideration of claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43.

I. Rejection of claims under §112

The Examiner rejected claims 36-43 under §112 ¶2, arguing that the use of the term "environment" renders the claims indefinite. First, Applicants point out that, of the rejected claims, the term "environment" is neither expressed nor incorporated in claims